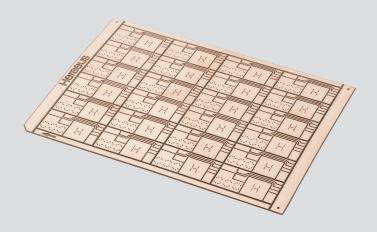


Condura®.Extra

Metal Ceramic Substrates Condura.extra DPIS(1)



ZTA DCB facts

- Thicknesses⁽²⁾: 0.25mm/0.32 mm
- Direct Copper Bonding Cu-OFE Thicknesses⁽²⁾: 0.2 mm/0.3 mm
- Single unit or master card size 7 " x 5 " (usable area)
- Surface finish: bare Cu, Ni, Ni/Au, Ag (partial Ag on request)

Key properties

- Dimples (stress relief)
- DMC (Data Matrix Code)

Process features:

- Grinding surface treatment
- Laser technology
- US Scan
- AOI (Automatic Optical Inspection)

Key features

■ Higher reliability version and economic version available

Main properties substrate (DCB)

	Rating	Unit
Thermal conductivity @ 20 °C	≥	22W/m.K
Bending strength	600 - 650	MPa
Die electric strength	≥	20kV/mm

^{*}Picture: substrate layout by courtesy of Fraunhofer IISB

⁽¹⁾ Development Product Information Sheet, preliminary values

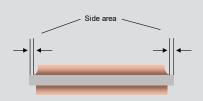
⁽²⁾ Different material combinations on request

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Material properties raw Al₂O₃⁽³⁾

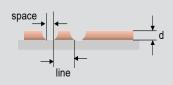
	Rating	Unit
Density	> 3.95	g/cm³
Electrical resistivity	≥ 10 ¹⁴	Ohm·cm

Copper free area



Thickness Cu [mm]	Min. side area [mm]
0.20	0.20
0.30	0.25

Structuring



Thickness Cu [mm]	Min. space [mm]	Min. line [mm]
0.20	0.40	0.40
0.30	0.50	0.50

Etching tolerance



Tolerance length & width	Thickness Cu
[mm]	[mm]
$T_{typ.} = \pm 0.15$	d = 0.2
$T_{typ.} = \pm 0.20$	d ≤ 0.3
$T_{typ.} = \pm 0.20$	d ≤ 0.4

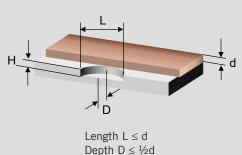
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Tolerance and chip off

Tolerance d Mismatch $M \le 0.1 \text{ mm}$ Tolerance of total thickness d = +7 % / -10 %

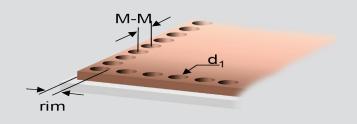
Tolerance of total thickness d after grinding = +7% / -15%

Chip-off at ceramic edge



Height H ≤ ½d

Dimple structure



Thickness Cu	Dimple area	Dimple diamter	Dimple pitch
[mm]	rim [mm]	d ₁ [mm]	M-M [mm]
0.20			
0.30			
0.40			

Dimensions

General dimensions	Rating (mm)
Master card	138 x 190.5
Max. usable area	127 x 178
Minimum dimension for	10 x 10
ceramic thickness ≤ 0.32 mm	(smaller on request)

Tolerances of single parts	Rating (mm)
Ceramic thickness 0.32 mm	+ 200 μm - 50 μm

Warpage behavior depends on specific layout, single part size and material combination and can only be specified after initial sample preparation.

Surface	plating	

Plating Method	Thickness (um)
Electroless Ni	3 - 7 (9% ± 2 % P)
Electroless NiAu	Ni 3 - 7 (9 % ± 2 % P)
	Au Class 1: 0.01 - 0.05
	Au Class 2: 0.03 - 0.13
Ag	0.2 - 0.3

.2.2021, Layout: CF

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Metal & hole properties

Roughness

Rmax = $50 \mu m$

 $Ra \le 3.5 \ \mu m$ $Ra \le 1 \ \mu m$

 $Rz \le 24 \ \mu m$ $Rz \le 16 \ \mu m$

Different roughness by request

Minimum hole diameter

 $d_{hole} = 1 \text{ mm}$

Electrical conductivity raw copper

 $G_{CU} = 58 \cdot 10^6 \text{ S/m}$

Thickness Cu Copper peeling Strength

0.30mm > 4 N/mm

HET Academy R&D Application Center

Besides offering Assembly
Materials, Bonding Wires and
Metal Ceramic Substrates,
Heraeus Electronics provides
matching material solutions and
R&D oriented partnerships to

Application conditions and assembly optimization

Thermal shock test cycles

-55 °C up to +150 °C

Information upon request

Customized surface for assembly process

Optimization of surface and assembly process parameters available or in development cooperation for:

- Sintering
- Solder wetting
- Heavy wire bondability

Heraeus Electronics offers:

■ Condura® +

- Reliable IATF 16949 certified supply of:
- ✓ Condura®.prime AMB-Si₃N₄ (active metal brazed Si₃N₄)
- ✓ Condura®.extra DCB-ZTA (zirconia-toughened alumina)
- ✓ Condura®.classic DCB-Al₂O₃ (direct copper bonded Al₂O₃)
- Engineering Services (Simulation, Prototype Design & Assembly, Testing and Qualification, Material Analysis)
- ✓ Pre-applied sinter / solder
- To be your competent one-stop materials solutions partner!

for example:

Americas

Phone +1 610 825 6050 electronics.americas@heraeus.com

Asia Pacific

Phone +65 6571 7649 electronics.apac@heraeus.com

China

Phone +86 53 5815 9601 electronics.china@heraeus.com

Europe, Middle East and Africa Phone +49 6181 35 4370 electronics.emea@heraeus.com

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